

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

1. (currently amended): An island projection-modified part which has, on the substrate thereof, island projections having a width of from 5 to 300 μm and a height of from 2 to 200 μm and in which the island projections are roundish as a whole, and the number of the island projections is from 20 to 5,000/ mm^2 , wherein the island projections are formed of glass and they are spherical, partly spherical, semispherical, bell-shaped or mountain-shaped or are in the form of a mixture of two or more of these shapes and wherein at least some island projections do not overlap with each other, whereby a portion of the substrate is exposed and separates at least some of the individual island projections.

Claim 2 (canceled).

3. (currently amended): ~~The island projection-modified part as claimed in claim 1~~ An island projection-modified part which has, on the substrate thereof, island projections having a width of from 5 to 300 μm and a height of from 2 to 200 μm and in which the island projections are roundish as a whole, and the number of the island projections is from 20 to 5,000/ mm^2 , wherein the island projections are formed of glass and they are spherical, partly spherical, semispherical, bell-shaped or mountain-shaped or are in the form of a mixture of two or more of

these shapes, wherein the island projections are formed on a glass-sprayed film that is formed on the substrate and wherein at least some island projections do not overlap with each other, whereby a portion of the substrate is exposed and separates at least some of the individual island projections.

4. (previously presented): The island projection-modified part as claimed in claim 1, wherein the glass to form the island projections is quartz glass.

5. (original): The island projection-modified part as claimed in claim 3, wherein the sprayed film is of quartz glass.

Claim 6. (canceled).

7. (original): A film-forming device that comprises the island projection-modified part of claim 1.

8. (original): A plasma-etching device wherein the island projection-modified part of claim 1 is used for the part on which a film may be deposited or etched through plasma etching.

9. (original): A plasma-cleaning device wherein the island projection-modified part of claim 1 is used for the part on which a film may be deposited or etched through back sputtering.

10. (previously presented): The island projection-modified part as claimed in claim 22, wherein the island projections are formed of ceramic and/or metal, and they are mountain-shaped and/or bell-shaped.

11. (original): The island projection-modified part as claimed in claim 1, wherein the mean ratio of the height to the width (height/width) of the island projections falls between 0.3 and 1.5.

12. (original): The island projection-modified part as claimed in claim 10, wherein the surface of the substrate on which the island projections are formed has a surface roughness Ra of at most 5 μm .

13. (original): The island projection-modified part as claimed in claim 10, wherein the island projections are formed of materials having a different melting point and the material having a high melting point is enveloped in the other material having a low melting point to give the island projections.

Claims 14. - 17. (canceled).

18. (original): A film-forming device wherein the part of claim 10 is used for the part that may receive a filmy deposit formed thereon through PVD or CVD.

19. (original): A plasma-etching device wherein the part of claim 10 is used for the part on which a film may be deposited or etched through plasma etching.

20. (original): A plasma-cleaning device wherein the part of claim 10 is used for the part on which a film may be deposited or etched through back sputtering.

Claim 21. (canceled).

22. (currently amended): An island projection-modified part which has, on the substrate thereof, island projections having a width of from 5 to 300 μm and a height of from 2 to 200 μm and in which the island projections are roundish as a whole and do not have any sharp edge, and the number of the island projections is from 20 to 5,000/ mm^2 , wherein at least some island projections do not overlap with each other, whereby a portion of the substrate is exposed and separates at least some of the individual island projections.

Claim 23. (canceled).

24. (previously presented): The island projection-modified part as claimed in claim 22, wherein the mean ratio of the height to the width (height/width) of the island projections falls between 0.3 and 1.5.

25. (previously presented): The island projections-modified part as claimed in claim 22, wherein the island projections are formed of glass.

26. (new): The island projection-modified part as claimed in claim 3, wherein the thermal sprayed film formed on the substrate is closely structured having no voids with the size of 100 μm or more and is smooth.